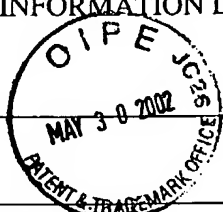


FORM PTO-1449
(REV. 7-80)U.S. DEPARTMENT OF COMMERCE
PATENT AND TRADEMARK OFFICEATTY. DOCKET NO.
RD-28,965SERIAL NO.
10/063,917INFORMATION DISCLOSURE STATEMENT BY APPLICANT
LIST OF ITEMSApplicant
Marc (NMN) SchaepekensFiling Date
05/23/02Group
1775

U.S. PATENT DOCUMENTS

*EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
LY	A1 4,871,580	10/3/89	Schram et al.			
LX	A2 6,110,544	8/29/00	Yang et al.			
	A3					
	A4					
	A5					

FOREIGN PATENT DOCUMENTS

	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES NO
	B1					
	B2					

OTHER INFORMATION (Including Author, Title, Date, Pertinent Pages, etc.)

24	C1	Application Serial No. 09/681,820, filed June 11, 2001, "Apparatus and Method for Large Area Chemical Vapor Deposition Using Multiple Expanding Thermal Plasma Generators".
	C2	Application Serial No. 09/836,657, filed April 17, 2001, "A Transparent Flexible Barrier for Liquid Crystal Display Devices and Method of Making the Same."
	C3	Application Serial No. 09,683,148, filed November 27, 2001, "Apparatus and Method for Depositing Large Area Coatings on Non-Planar Surfaces".
	C4	Application Serial No. 09,683,149, filed November 27, 2001, "Apparatus and Method for Depositing Large Area Coatings on Planar Surfaces".
	C5	Philips Research Password, "Flexible Displays Cast Off Rigid Constraints", Dr. Peter Slikkerveer, Issue 10, Issue 10, pp 5-7, January 2002.
	C6	Appl. Phys. Letter, "Etch Mechanism in the Refractive Index Silicon Nitride Plasma-Enhanced Chemical Vapor Deposition Process, Yeo Kuo, Volume 63, No. 2, pp 144-146, July 12, 1993
	C7	American Vacuum Society, "Transparent Barrier Coatings on Polyethylene Terephthalate By Single- and Dual-Frequency Plasma-Enhanced Chemical Vapor Deposition", A. S. da Silva Sobrinho et al, A, Volume 16, No. 6, pp 3190-3198, Nov/Dec 1998.
	C8	

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U.S. PATENT DOCUMENTS & PATENT APPLICATION PUBLICATION

*EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
	A1					
	A2					
	A3					
	A4					
	A5					
	A6					
	A7					
	A8					
	A9					

FOREIGN PATENT DOCUMENTS

		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES NO
2X	B1	WO 01/81649	1NOV01	PCT			X
↓	B2	EP0460966	11DEC91	European			X
	B3	FR 2712310	19MAY95				

OTHER INFORMATION (including Author, Title, Date, Pertinent Pages, etc.)

LX	C1	Osamu Fukumasa, "Synthesis of New Ceramics From Powder Mixtures Using Thermal Plasma Processing", Elsevier, Thin Solid Films, 390, pages 37-43, 2001.
	C2	
	C3	
	C4	
	C5	
	C6	
	C7	
	C8	

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